

**2022 EXHIBITOR
and SPONSOR
PROSPECTUS**

SPIE. ADVANCED LITHOGRAPHY+ PATTERNING

Exhibition: 1-2 March 2022

Conferences and Courses: 27 February-3 March 2022

San Jose, California, USA

RESERVE YOUR EXHIBITION
SPACE TODAY

spie.org/al22exhibitor



SPIE Advanced Lithography + Patterning

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San Jose, California, USA

The key event that drives the future of lithography research and applications



2,000
ATTENDEES



50+
EXHIBITING
COMPANIES



6
CONFERENCES



15
COURSES



500
TECHNICAL
PAPERS

Become a sponsor or exhibitor at the industry's most important event for lithography and patterning R&D, applications, sources, devices, tools, fabrication, and services. SPIE offers marketing opportunities to help you showcase your organization to leaders in the semiconductor industry.

Become a sponsor
spie.org/al22sponsor

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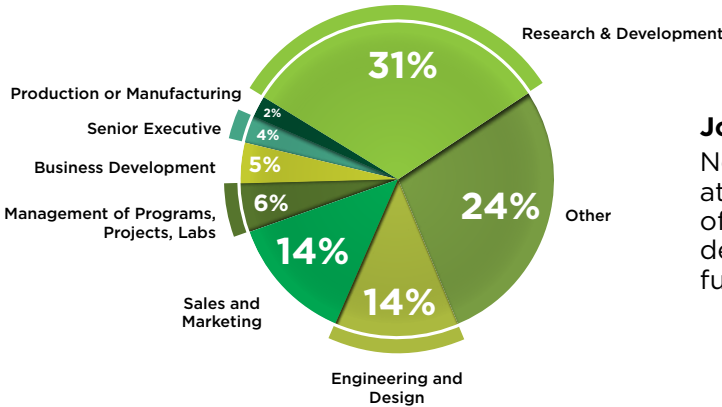
SPIE. ADVANCED LITHOGRAPHY+ PATTERNING

It's global.

More than 2,000 people attend SPIE Advanced Lithography + Patterning each year.*



It's business.



Job functions

Nearly half of total attendance is made up of R&D and product development job functions.*

It's a buyer-rich environment for the lithography and patterning industry.

Top purchase areas*:

Lithographic Equipment
Nanotechnology Products
Materials, Abrasives, Chemicals
Software
Optical Components: Lenses, Filters, Mirrors, and Accessories

Microtechnology
Cameras and Imaging Systems
Test and Measurement Equipment
Microscopes
Computing, Data

Processing Hardware
Optical Coatings, Thin Films
Detectors, Sensors
Lasers and Systems

*Statistics based on historical data.

SIGN UP TODAY

Connect with a highly qualified audience

Join us for two days of face-to-face interactions and networking opportunities. Space includes web and exhibition guide listings, free technical pass, exhibitor/poster receptions, and more. Exhibitors can also increase exposure and drive booth traffic by adding advertising or sponsorships.

EXHIBITION HOURS

Tuesday 1 March · 10:00 AM to 5:00 PM

Wednesday 2 March · 10:00 AM to 4:00 PM

Truly an industry event

More than 600 companies participate by sending attendees and authors, and nearly 60 companies exhibit each year.

Previous exhibitors at Advanced Lithography + Patterning:

2ndLook Solutions	Heidelberg Instruments, Inc.	Osiris International GmbH
3M Co.	HORIBA Instruments, Inc.	Pall Corp.
Amuneal Manufacturing Corp	ibss Group, Inc.	Philips Innovation Services PM B.V.
attocube systems, Inc.	INKO Industrial Corp.	POLLEN Metrology
Banner Industries, Inc.	Inspectrology, LLC	Pozzetta, Inc.
Benchmark Technologies	J.A. Woollam	Qoniac GmbH
C&D Semiconductor Services, Inc.	JENOPTIK Light & Optics	Raith America, Inc.
Cadence Design Systems, Inc.	JEOL, USA, Inc.	SAES Group
Canon U.S.A., Inc.	JSR Micro, Inc.	Sage Design Automation, Inc.
Carl Zeiss SMT GmbH	Kayaku Advanced Materials, Inc.	scia Systems GmbH
CEROBEAR GmbH	Mentor, a Siemens Business	SCIL Nanoimprint Solutions
Cosmotec, Inc.	Micro Lithography, Inc.	SCREEN SPE USA, LLC
Coventor, Inc.	micro resist technology GmbH	Seiwa Optical America, Inc.
CyberOptics Corporation	Microlight3D	Semiconductor Digest
Energetiq Technology, Inc.	Mitsui Chemicals America, Inc.	SEQENS
Entegris, Inc.	Nextin, Inc.	Shin-Etsu MicroSi, Inc.
GenlSys, Inc	NTT Advanced Technology Corp.	Spin Memory, Inc.
Gudeng Precision Industrial Co., Ltd.		Synopsys, Inc.
		TEL - Tokyo Electron U.S. Holdings
		Vistec Electron Beam GmbH
		XEI Scientific, Inc.
		Zygo Corporation

Reserve your space early to secure the best location.
spie.org/al22exhibitor

Sponsorships

Connect with leaders from the semiconductor industry

Find the sponsorship that fits your needs and budget. Opportunities range from receptions and plenary sessions to lanyards, sections of the conference app, and more. Review the sponsorship contract online for a full list of options and pricing.

Sponsors are recognized in pre-show publicity, online, and at the event. Exhibitors enjoy discounted rates; non-exhibitor pricing is also available.

Previous sponsors at Advanced Lithography + Patterning

Applied Materials, Inc.
ASML Netherlands B.V.
Carl Zeiss SMT GmbH
DuPont Electronics & Imaging
EMD Performance Materials Corp.
FUJIFILM Electronic Materials U.S.A., Inc.
Gigaphoton USA, Inc.
Heraeus Epurio, LLC
Hitachi High Technologies America, Inc.
KIOXIA Corp.

KLA Corp.
Lam Research Corp.
Mentor, a Siemens Business
Nikon Precision, Inc.
Nova Measuring Instruments, Ltd.
NuFlare Technology, Inc.
Qoniac GmbH
Rigaku Innovative Technologies, Inc.
SCREEN SPE USA, LLC
TEL



30 sponsorship options available

Choose from online and on-location sponsorship options that align with your marketing goals.

Some sponsorships have limited availability and some are exclusive, so secure your sponsorship early.

spie.org/al22sponsor

SHOWCASE YOUR COMPANY AMONG LEADERS

EXHIBITOR AND SPONSOR PROSPECTUS



Engage with the semiconductor community by becoming a sponsor or exhibitor at SPIE Advanced Lithography + Patterning 2022.

Become a sponsor
spie.org/al22sponsor

Become an exhibitor
spie.org/al22exhibitor

Contact SPIE Sales

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